

# **OBUDA UNIVERSITY**



## **Doctoral School on Materials Sciences and Technologies**

Institute of Technical Physics and Materials Science  
Centre for Energy Research

### **3<sup>rd</sup> Semester Report On ' Non-Destructive Optical Mapping Tool From Cheap Parts '**

By : **Berhane Nugusse Zereay**  
Supervisor : **Prof. Dr. Miklós Fried**

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# OUTLINE

1. Introduction
  - 1.1. Aim of the Research
  - 1.2. Research Methods
  - 1.3. Characterization methods
2. Results of the Previous Semester
3. Results of the Actual Semester
4. Plans For the Future Work

# 1. Introduction

## Spectroscopic Ellipsometry (SE)

- Non-destructive, non-invasive and non-intrusive optical technique.
- Measures the relative change in polarization state of the measurement beam.
- The two SE measurable values: Amplitude ratio ( $\psi$ ) and phase difference ( $\Delta$ ) between the **p**- and **s**-polarizations.
- $\psi$  and  $\Delta$  correspond to the wavelength of the light beam ' $\lambda$ ' and the angle of incidence of the beam ' $\theta$ ' at the sample surface.
- Major Steps: Measurement, Data interpretation, Modelling, Fitting, Evaluation and Results.

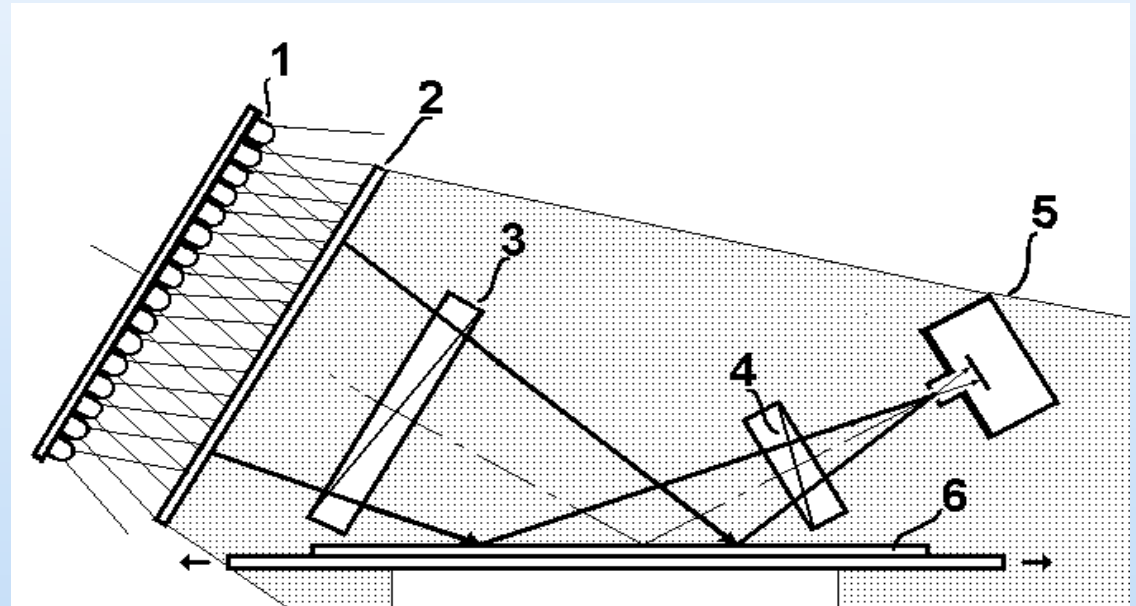
# 1.1. Aim of the Research

- Making an optical mapping tool *prototype* from cheap parts like:  
Tablets, monitors and big screen LCD,LED TV
- Programming the data collection and data processing software
- Making measurements on selected samples and determining the precision of the prototype.

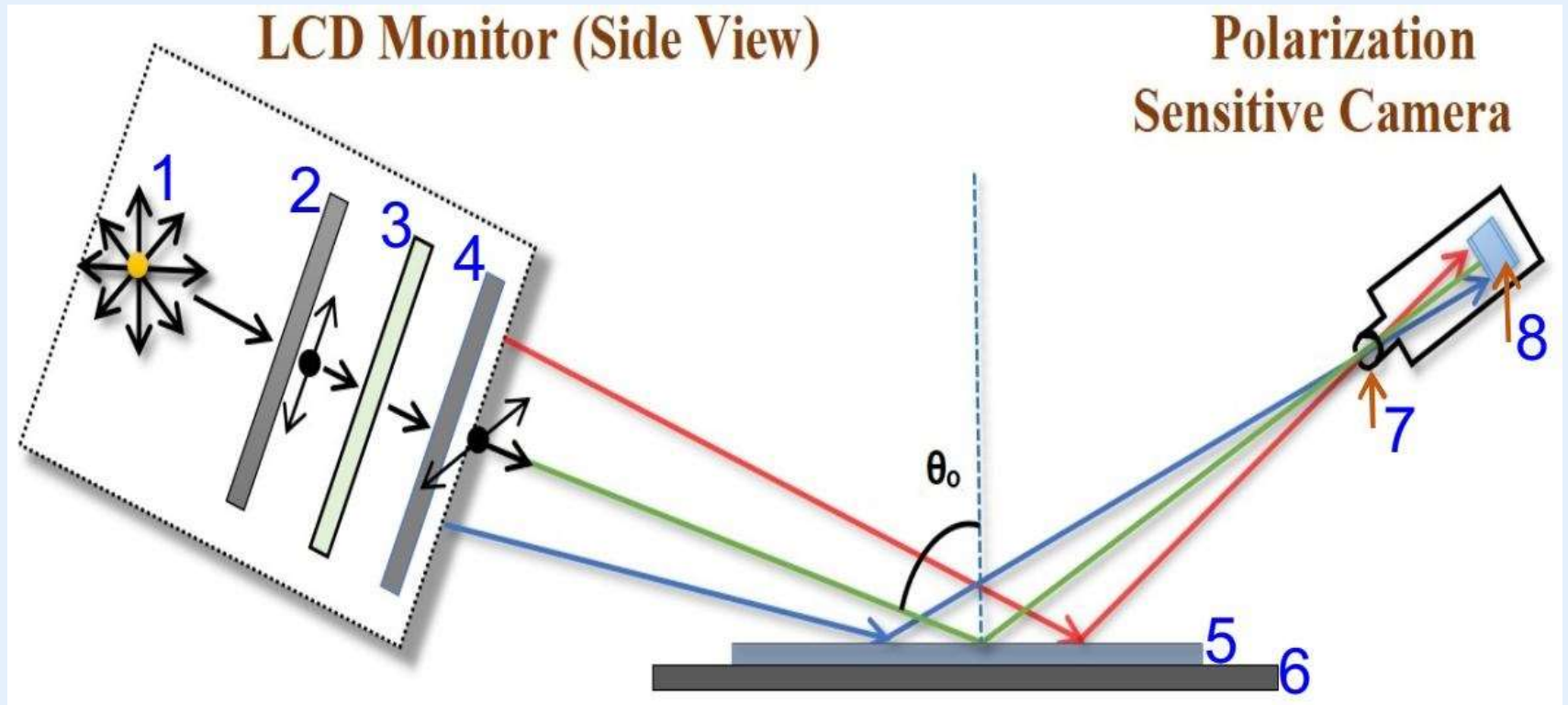
# 1.2. Research Methods

## Original Concept of Prototype building using different parts

1. Light-source (LED-panel)
2. Diffuser sheet
3. Film-polarizer
4. Analyzer
5. Detector (pin-hole + CCD-detector) and
6. Sample



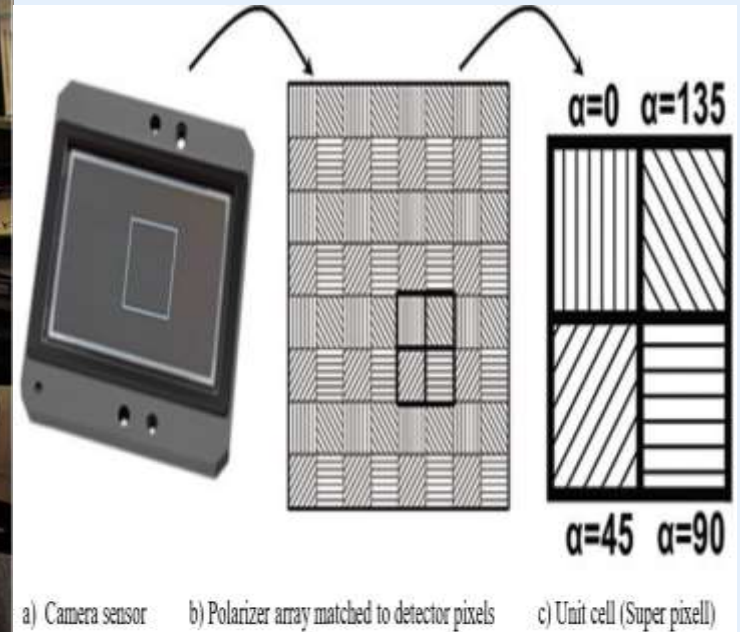
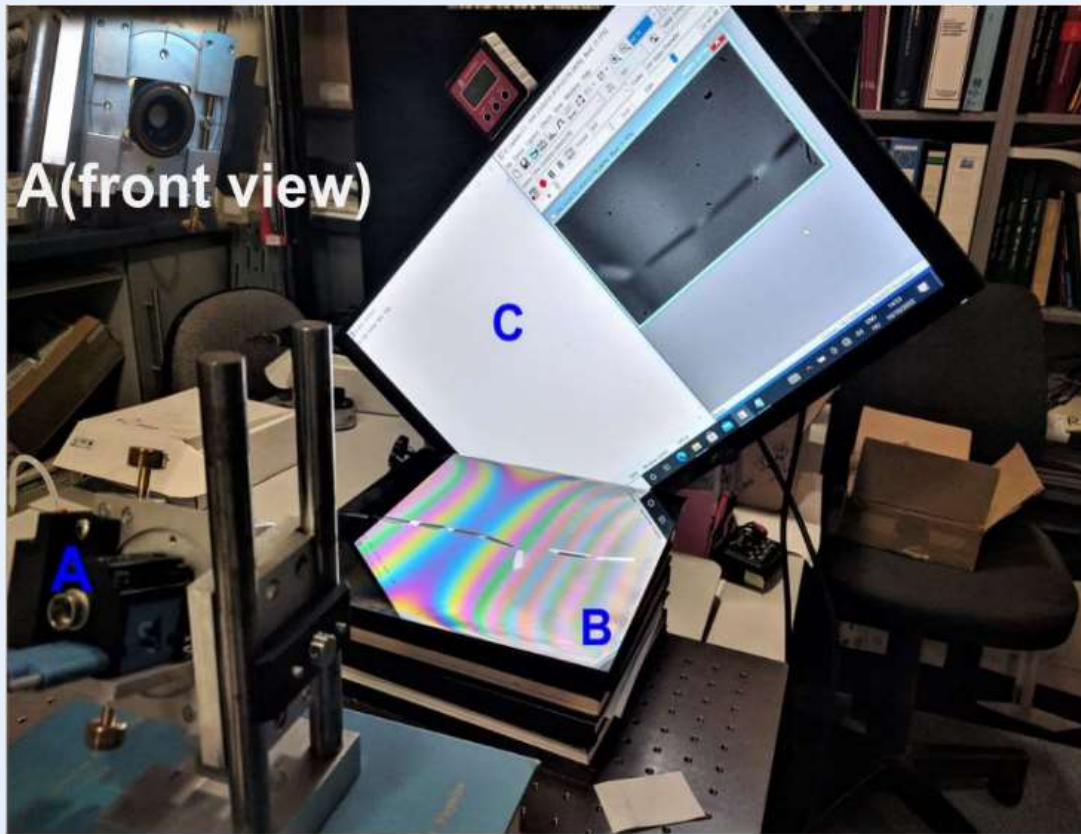
**Fig. 1:** Original concept of the non-collimated beam ellipsometer



**Fig. 2:** New concept of the non-collimated beam ellipsometer prototype from cheap parts

- |                               |                       |                        |
|-------------------------------|-----------------------|------------------------|
| 1) Light source               | 2) Vertical polarizer | 3) Liquid crystal cell |
| 4) Horizontal polarizer       | 5) Sample             | 6) Sample holder       |
| 7) Pin hole (sub-mm size) and |                       | 8) Camera sensor       |

# The new concept is without the rotating polarizers



a)

b)

**Fig. 3:** a) Experimental set up

A) Polarization sensitive camera    B) Sample + holder    C) LCD monitor

b) Schematic structure (CMOS Pregius Polarsens sensor),

**NB.** CMOS sensor is Integrated 4-Directional Wire Grid Polarizer

## 1.3. Characterization methods



- **Fig. 4:** Rotating Compensator Spectroscopic Ellipsometer (M2000DI)
- The M2000DI ellipsometer is used for control measurements.

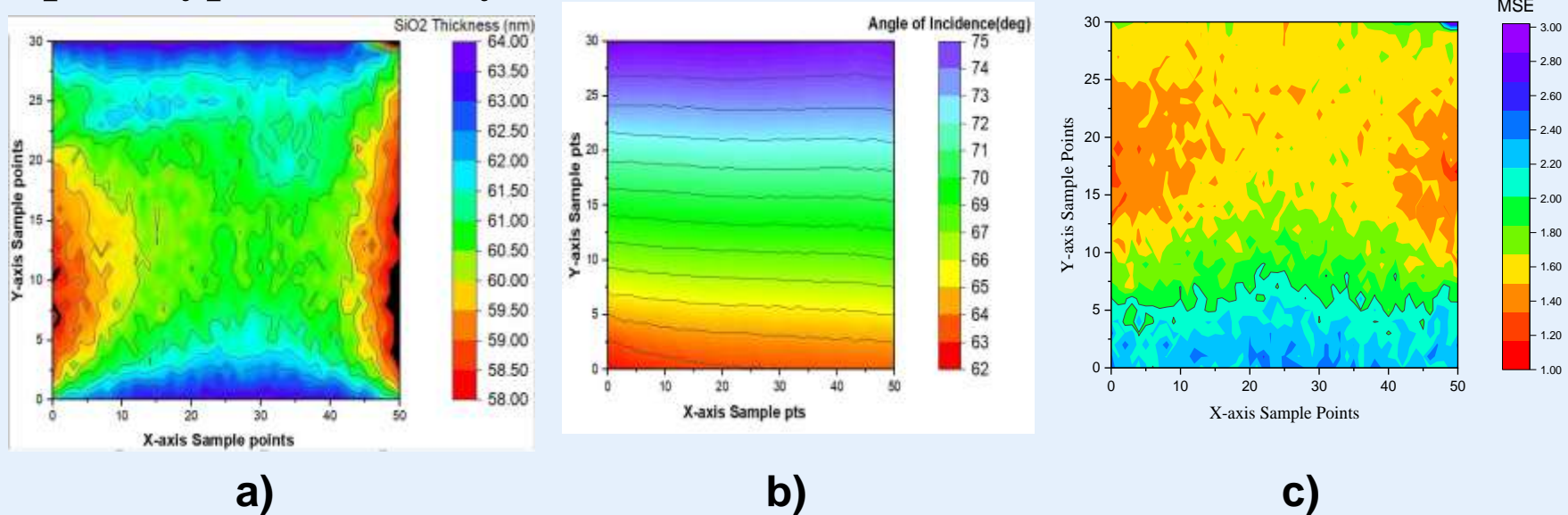


# Rotating Compensator Spectroscopic Ellipsometer

- Provides fast and very accurate thin film characterization over a wide spectroscopic range.
- Measures film thickness and optical constants on single or multilayer stack.
- Extreme sensitivity for very thin over layers even below 1 nm thickness.
- But it is indirect analysis technique.
- Similar measurements will help the calibration of the prototype.

## 2. Results of the Previous Semester

- 60nm,  $\text{SiO}_2/\text{Si}$  sample *angle of incidence*(AOI) calibration, thickness measurement, MSE analysis was done.
- Only, less than 2 nm thickness difference between the M2000 and our prototype, with very low MSE.



**Fig. 5:** a) Thickness vs position  
b) Angle of incidence versus position  
c) MSE vs position

# 3. Results of the Actual Semester

## Actual Semester Aim :

Calibration of the prototype imaging tool from different positions and preliminary analysis of  $WO_3$ - $MoO_3$  combinatorial mixed layers on a 30x30 cm glass sheet.

- **First step:** AOI calibration using  $SiO_2/Si$  sample by
  - Placing the oxide sample at three different positions
  - Measuring the **AOI, MSE**
  - Choosing the points of lower MSE values and
  - Developing single map calibration of the MSE and **AOI**
- **Second Step:**

Preliminary analysis of  $WO_3$ - $MoO_3$

Analysis : Thickness, EMA

(Effective Medium Approximation)

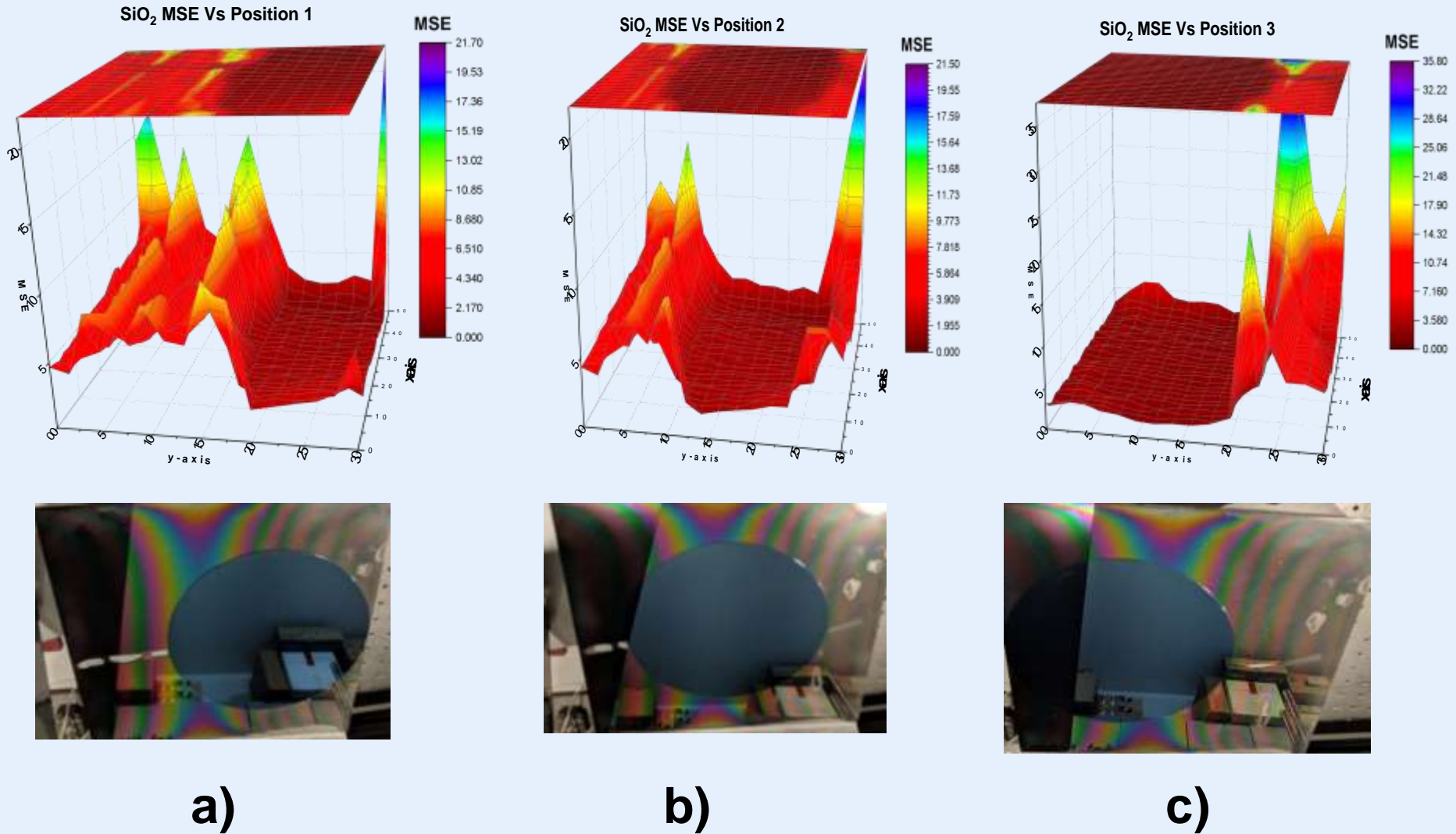
from the AOI calibration



**Fig. 6:**  $WO_3$ - $MoO_3$  Sample

# 3. Results of the Actual Semester

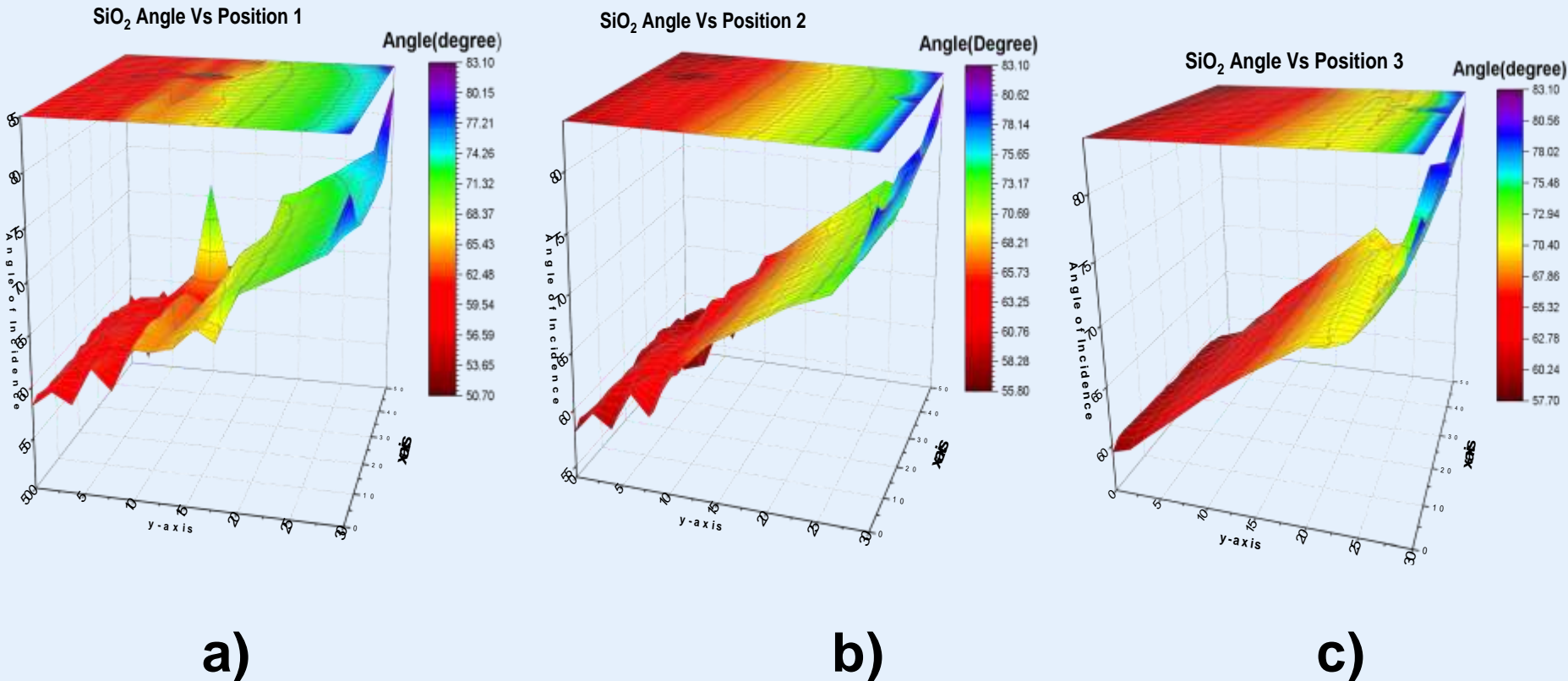
## 3.1 SiO<sub>2</sub> MSE calibration



**Fig. 7:** 3D maps of the MSE values of SiO<sub>2</sub> vs Positions 1,2 and 3 respectively. **10**

# 3. Results of the Actual Semester

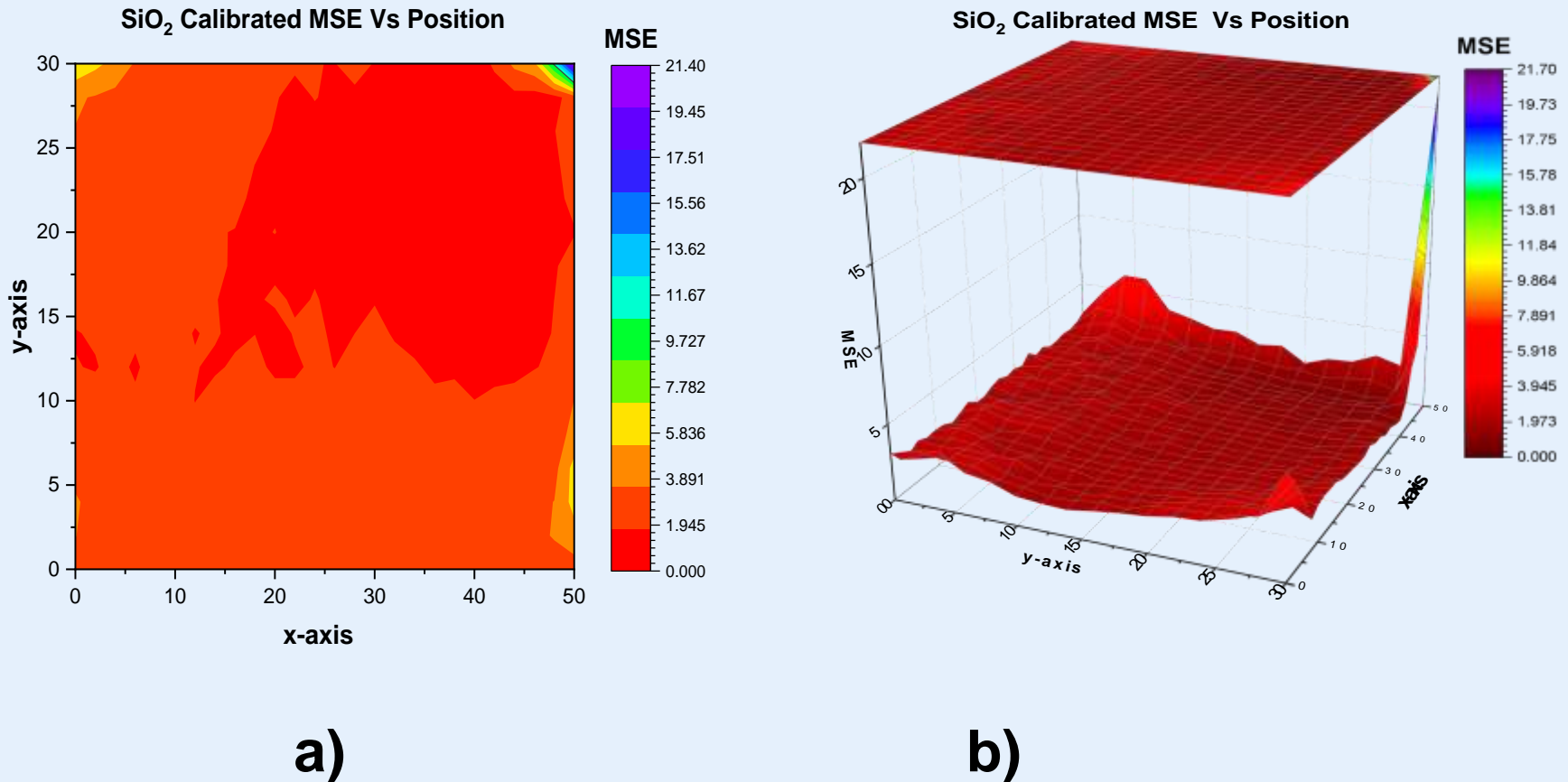
## 3.2. SiO<sub>2</sub> thickness calibration



**Fig. 8.** 3D map of the angle of incidence values from three different positions 1,2 and 3, respectively

# 3. Results of the Actual Semester

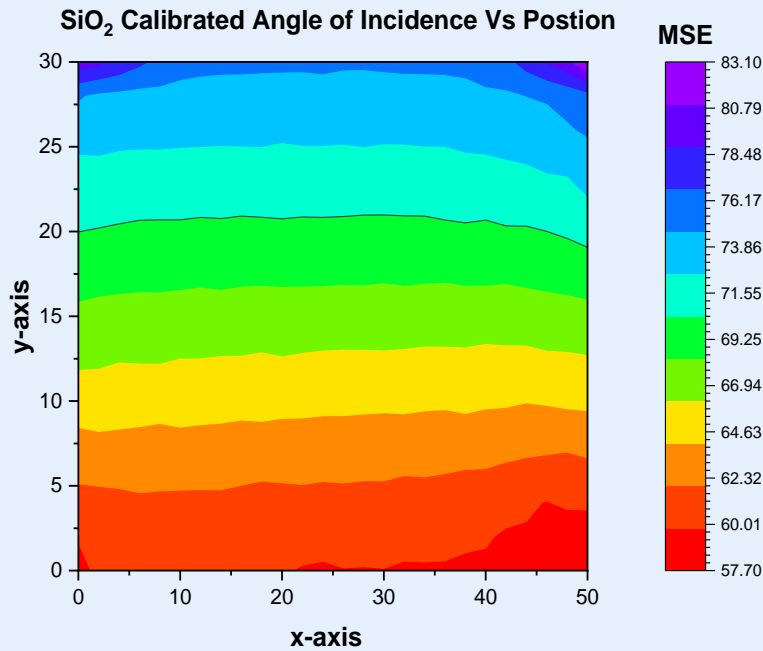
## 3.3. Calibrated MSE, SiO<sub>2</sub>



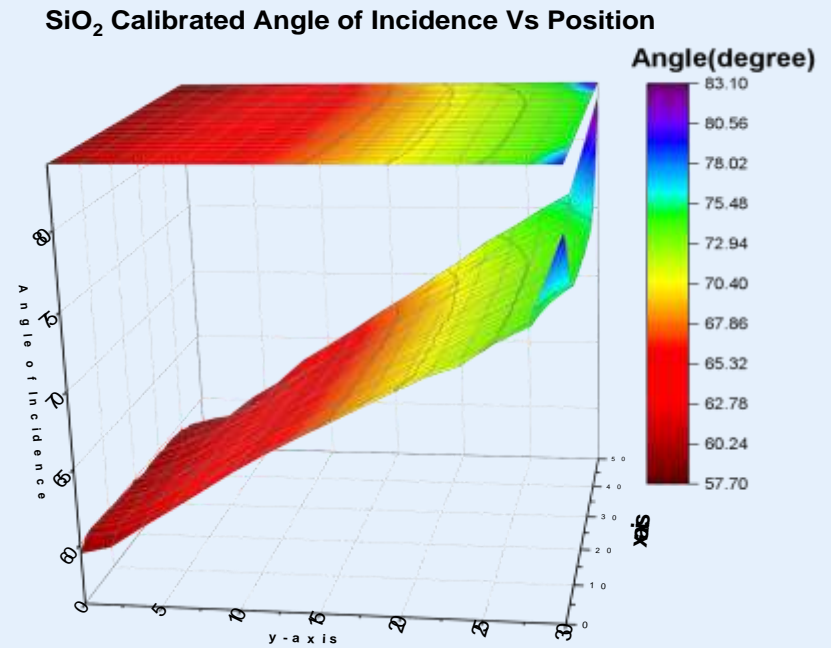
**Fig. 9.** 2D and 3D map of the MSE calibration vs Position ,respectively

# 3. Results of the Actual Semester

## 3.4 Calibrated thickness , SiO<sub>2</sub>



a)

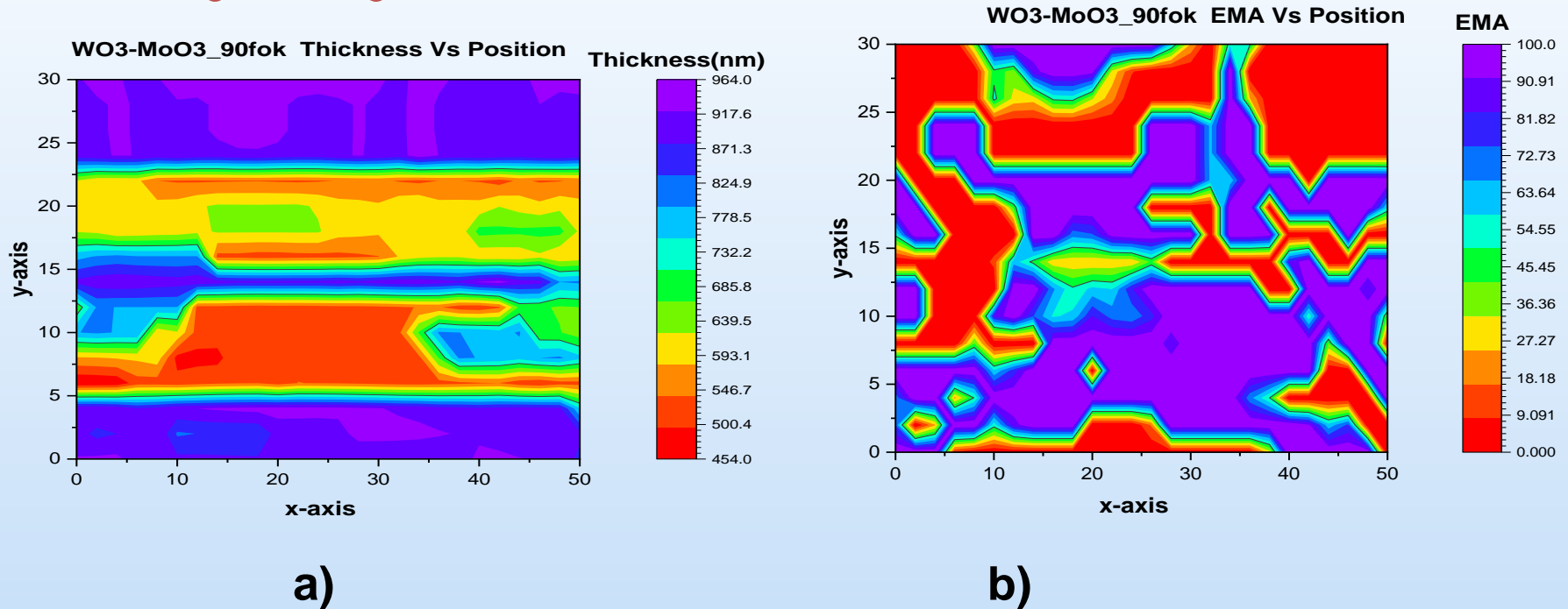


b)

**Fig. 10.** 2D and 3D map of the angle of incidence values vs Position ,respectively

# 3. Results of the Actual Semester

## 3.5 WO<sub>3</sub>-MoO<sub>3</sub> Measurements



**Fig. 11:** WO<sub>3</sub>-MoO<sub>3</sub> thickness and EMA vs Position, respectively.

- WO<sub>3</sub>-MoO<sub>3</sub> is mostly transparent to the visible light range, hence resulting higher errors on the maps above.
- The Imaging prototype is very sensitive within the visible range.



# General View of the Prototype tool

## Advantages

- The new prototype is fast imaging and made up of cheap parts
- Wide mapping area up to 150cm is possible .

## Limitations

- Only three wide wavelength bands (RGB ) are in action ,which narrows the range of the light band source.
- ‘0.1 degree’ angle uncertainty from the digital angle gauge used in rotation angle of the LCD, which affects incident polarization state of the light.

# Activities

**Table 1. Courses completed in this actual semester**

Course Neptun Code	Course Title	Instructor	Cr. Pts.
OATBGEN1ND	Band gap Engineering	Dr. Nemcsics Ákos	6
OATNOMK1ND	Numerical methods for the evaluation of optical measurements	Dr. Petrik Peter	6
OATSZFA1ND	Solid-state light sources and their application	Dr. Zsolt Jozsef Horvath	6
OATBESZ3ND	Research report III	Dr. Recskiné Dr. Borsa Judit Ilona	6
QATKUTP3ND	Research project III.	Dr. Recskiné Dr. Borsa Judit Ilona	10
		<b>Semester Total Cr. pts</b>	<b>34</b>

# Activities

## Conferences

- “**Carla Camp Graz- the Photonics Career Hub**” (Photonics Austria), University of Graz, Austria, on 21-23 September 2022
- “**XXXVII Kando Conference 2022**”, Obuda University, on 3-4 Nov. 2022
- **Online webinars**, “Advanced Photonics Webinars ” on Vectorial Metrics in Optics”, on 14<sup>th</sup> Dec 2022, and others.

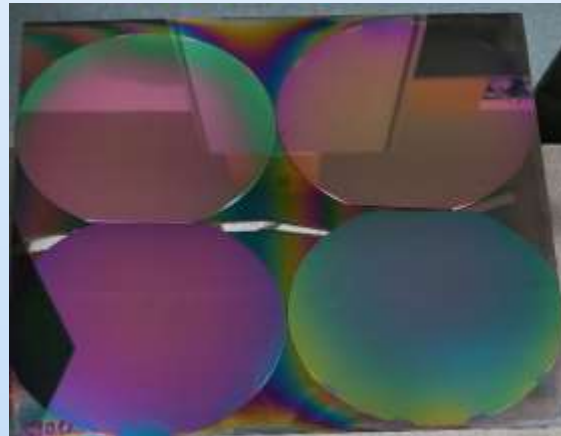
## Publication

- **Accepted publication:**  
Submission TSF-D-22-00891R1  
Title, “*Non-destructive optical imaging tool from cheap parts*”  
Berhane Nugusse; György Juhász; Csaba Major; Péter Petrik;  
Sándor Kálvin; Zoltán György Horváth; Miklos Fried  
Thin Solid Films, VSI:ICSE-9

## 4. Plans For the Future Work

- Different samples, Poly silicon samples, will be considered to further cross check the precision, sensitivity and range and limits of the prototype for a better and broader scope and understanding of the optical mapping tool.

**Fig. 12:** Poly Si samples



- The Wollam M2000 ellipsometer will be used for control measurements

**köszönöm !**